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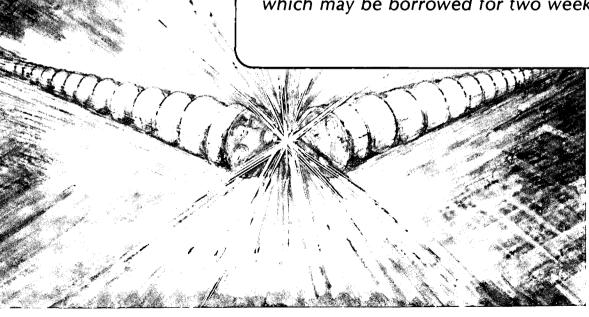
The Kinetics of H⁻ Ion Formation in Hydrogen Plasmas Studied Using Vacuum Ultraviolet Laser Absorption Spectroscopy

A.T. Young, G.C. Stutzin, A.S. Schlachter, K.N. Leung, and W.B. Kunkel

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THE KINETICS OF H- ION FORMATION IN HYDROGEN PLASMAS STUDIED USING VACUUM ULTRAVIOLET LASER ABSORPTION SPECTROSCOPY

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The chemical kinetics occurring in medium electron-density hydrogen plasmas has been the subject of many recent investigations. In particular, the processes taking place in plasmas used as hydrogen ion sources have come under close scrutiny. However, in spite of the recent work, the mechanism for negative-ion production is not well understood. One complicating factor in the study of the plasma chemistry is the difficulty of making measurements of the plasma constituents in situ, that is, in the plasma. This is due to the fact that the plasma produces a large photon and charged particle background which obscures the signal from most detection techniques. To overcome these difficulties and produce in situ measurements of H and H2, VUV laser absorption spectroscopy has been developed. This technique has been used to study the populations present in these plasmas under various conditions, revealing the kinetic processes taking place.

The most widely accepted model of H⁻ formation in a "volume" source invokes the process of dissociative attachment.³ In this process, vibrationally-excited molecules, $H_2(v^*)$, react with low-energy electrons to form H⁻, as shown in eqn. (1).

$$H_2(v^*) + e^- (\leq 2eV) \xrightarrow{\sim} H^- + H$$
 (1)

 H_2 with v > 5 are expected to be the most active species, as the cross sections for reaction (1) increase dramatically with vibrational level. In this scenario, the presence of highly-vibrationally-excited molecules is essential. The collision energy of the reactants is also important, with collisions of ~1 eV energy more reactive than collisions of ≥ 10 eV for producing H. Finally, the reaction rate for the reverse reaction is also non-negligible and dependent on collision energy. Thus, determinations of the density and translational energy distribution of the H and H_2 are crucial for developing and testing the mechanisms of H- formation. VUV laser absorption has been used to measure the absolute, state-specific densities of these important species.

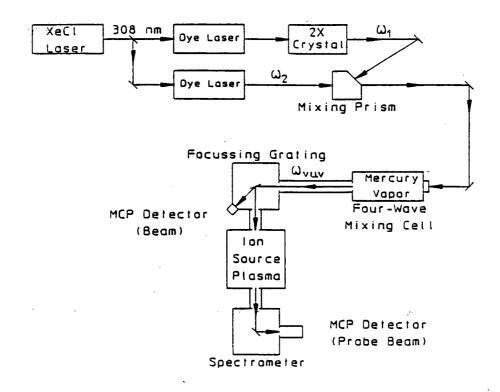


Figure 1. Experimental apparatus for vuv absorption spectroscopy.

The experimental apparatus has been previously described.⁴ This is shown schematically in Fig. 1. Very briefly, narrow-band, directional, and continuously tunable VUV radiation is generated by focussing the highintensity light from two excimer-pumped pulsed dye lasers into a mercury-vapor oven where four-wave sum frequency mixing takes place. The resulting VUV photon energy $\varepsilon_{vuv} = 2\varepsilon_1 + \varepsilon_2$ where ε_1 and ε_2 are the energies of the photons from the dye lasers. The VUV beam is split into two beams, one of which passes through the plasma of interest, and is measured with a microchannel-plate (MCP) detector. The other beam is measured without attenuation and is used for normalization. Using known values of the oscillator strength for H2 and H transitions allows us to compute the H₂ and H concentrations in the plasma. The final H₂ states for these measurements are specific rovibrational levels of either the B $^{1}\Sigma_{u}^{+}$ or the C $^{1}\Pi_{u}$ electronic states. For H detection, Lyman $\beta(n=3\leftarrow 1)$ or $\gamma(n=4\leftarrow 1)$ transitions are used.

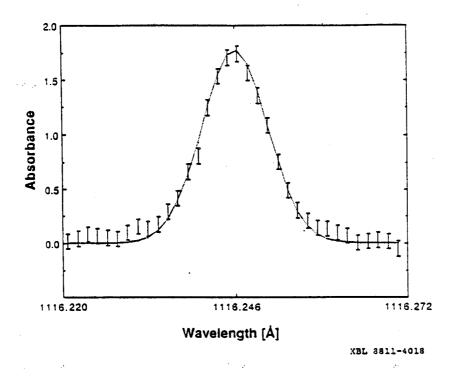


Figure 2. VUV absorption spectrum of vibrationally-excited of H₂. Transition observed is the (B-X) (3-1) R(2) line,

Figure 2 shows a typical absorption spectrum of H₂. This figure depicts the Lyman B $^1\Sigma_u^+ \leftarrow X$ $^1\Sigma_u^+$ (v' = 3 \leftarrow v" = 1) R(2) transition. The absorption illustrated corresponds to a density of 1.1 x 1012 H₂ molecules cm⁻³ in this state. Also shown in Fig. 1 is a least-squares Gaussian fit to the data points. From the measured Doppler line width, we obtain a translation temperature of 0.037 eV (450 K). A detection limit of ~3 x 109 molecules-cm⁻³-quantum state has been achieved. Hydrogen atom densities of ~5 x 1010 to 1 x 1014 have been measured with ion source discharge currents from 2 to 30 Amps and H₂ pressures up to 10 mTorr. H-atom temperatures from 0.06 eV (700 K) to ~1 eV (12000°K) have also been measured.

The H and H₂ populations can be determined as functions of the plasma parameters. Figure 3 shows representative data for the variation of the measured H-atom line density with H₂ pressure. The average H density is obtained by dividing the line density by the absorption path length, 30 cm. Data such as these are instrumental in determining the chemical processes important in these plasmas. In particular, vibrational distribution measurements of H₂, such as that in Figure 4, will provide key evidence for determining the key H- formation reactions. These data represent the first measurements of H₂ populations with v>5 in an ion source plasma, and has important implications for the proposed mechanism.

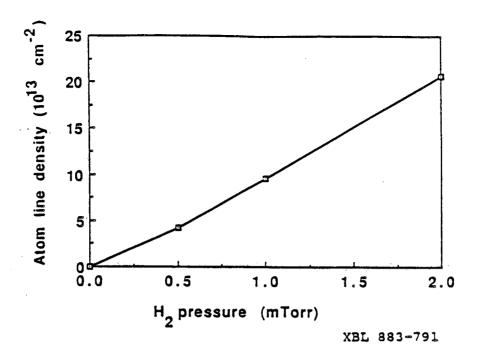


Figure 3. Hydrogen atom line density in a plasma discharge as a function of initial H₂ pressure. Discharge conditions were 25A and 130V.

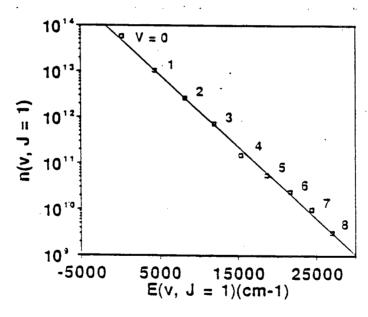


Figure 4. Vibrational state distribution of H₂ in ion source plasma.

In addition to complete H and H₂ measurements, the ion concentrations (e.g., H- and H+) will be determined mass spectrometrically. Comparison of the experimental data to the kinetic models of these plasmas will be made, and the implications to H- formation will be discussed.

Acknowledgement

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